



#### Thin Film Photovoltaic Solar Pilot Line

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### **Project Overview**

#### **Objectives:**

Establish a world-class thin film PV module capability

Attract PV manufacturing operations to the state

#### **Project Plan:**

Design, build and operate a state-of-theart generic thin film module facility





## **Project Overview**

Milestones/ Timeline :

- Year 1 Facility operational, sub-module experiments underway
- Year 2 Processing equipment operational, module level processing underway
- Year 3 Demonstration of effective module fabrication and performance, industry participation





# **Project Overview**

Milestones/ Timeline :

Year 2 – Processing equipment operational, module level processing underway

- Formed partnership with Florida based Mustang Solar
  - Deposition system budget leveraged by x5
  - Switched to RTR Processing
  - SS substrate development underway





#### Mustang Solar RTR Coating Machine

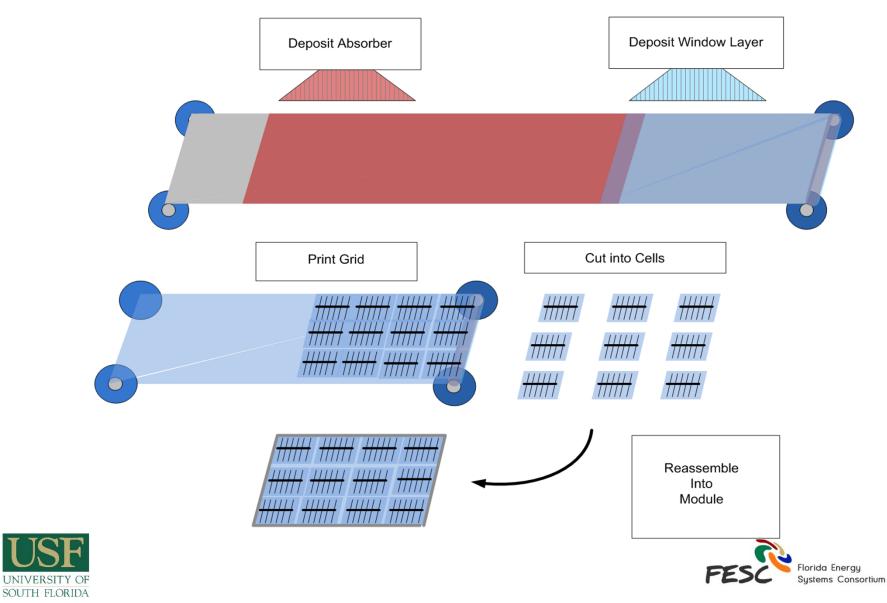




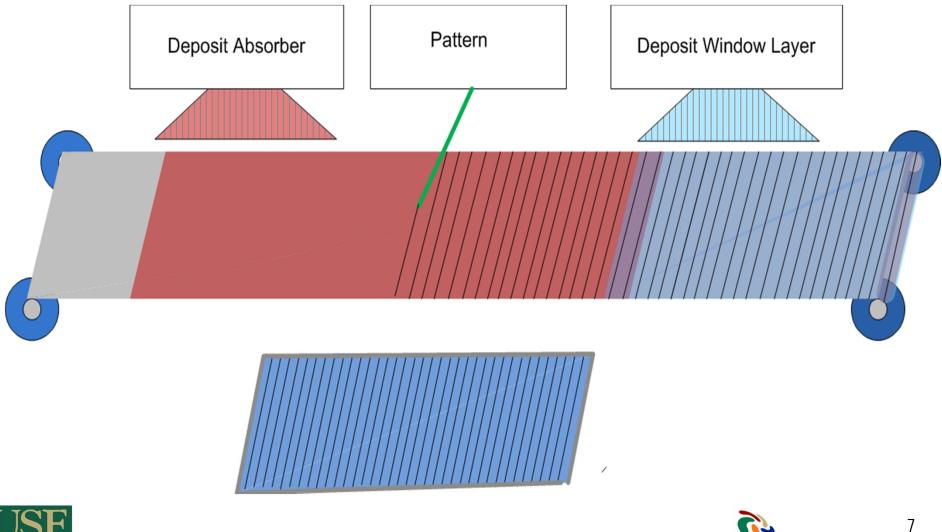


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#### **Discrete Cell Production**



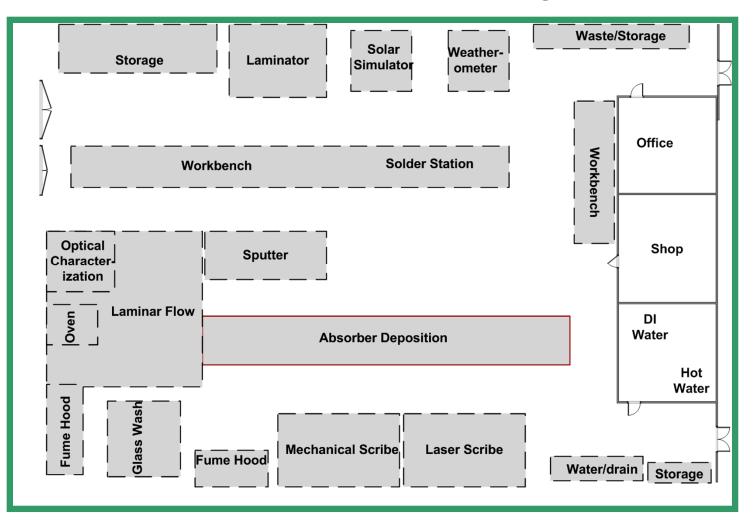
#### RTR Monolithic Integrated







#### Solar PV Laboratory







### Solar PV Laboratory

#### Capabilities

- Cell and Module Fabrication
  - Cell strings on SS roll
  - Interconnection and packaging into modules
  - Monolithic integration in a later phase
- Physical Vapor Deposition
  - Sputtering, Evaporation, Close Space Sublimation
- In-Situ Diagnostics
  - SS integrity, composition and thickness monitoring







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#### > 2SSS : 2 Step Solid Source(Se)

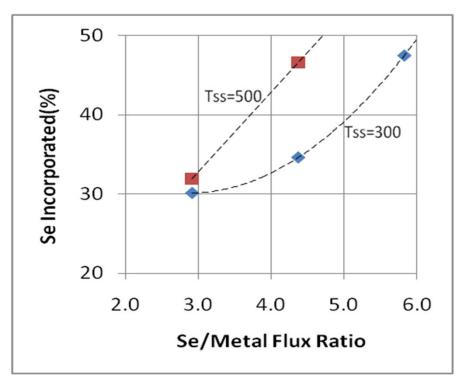
- Highest efficiencies attained with 2- or 3-step process
- Sticking coefficient for Se is low  $\rightarrow$  excessive Se use
- $\bullet$  Volatile Ga species form with Se  $\rightarrow$  loss of Ga





#### Se Incorporation

- Se incorporation is a function of substrate temperature(Tss) and Se/metal flux
- Approximately 50 atomic % Se is required
- In the first step of a 2SSS process Cu/Ga > 1 is required and a Tss of 300 °C is used which requires a Se/metal flux of order 6 to reach 50% Se

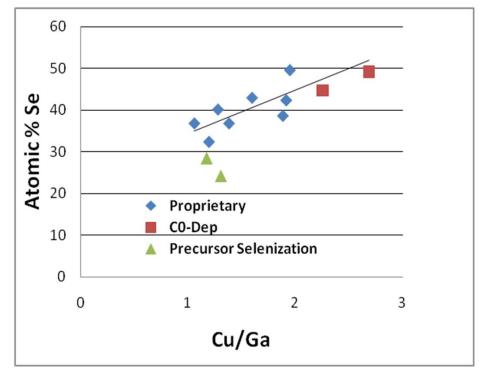






#### **Proprietary Process Developed**

- Co-deposition produces highest efficiency but is most difficult to manufacture
- Precursor Selenization is easier to manufacture but lower efficiency
- Se and Ga have a complex incorporation interdependence which results in inefficient incorporation
- New process spans the range in Se and Ga utilization between the two "endpoint" processes

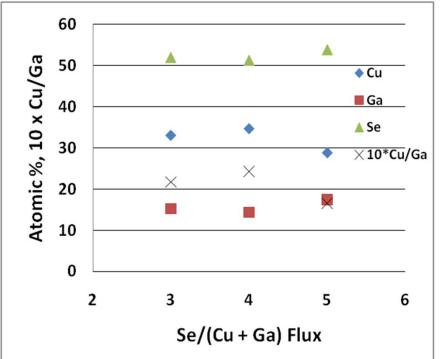






#### **Proprietary Process Provides Additional Control**

- Additional control of the proprietary process maintains 50% Se content over a range of Cu/Ga ratios
- 50% Se can be attained at Cu/Ga of 1.7 compared to a value of 2.8 for codeposited films indicating a significant reduction in Ga loss
- Allowing a small increase in Cu/Ga from 1.7 to 2.1 results in significant reduction in Se flux ratio from 5 to 3 while maintaining Se at 50%







#### Conclusions

- A partnership with a Florida based industrial partner has been formed
- The main processing tool for the thin film pilot line is being built with x5 leveraging of budgeted funds
- The processing approach has been switched to roll-to-roll on a stainless steel web
- Lab scale experiments are being conducted to develop new processing pathways
- A proprietary process for improved control and utilization of Ga and Se has been developed



